00862.022151



## **PATENT APPLICATION**

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

in re Application of:	) Eveninen II Newson	
Masaya OGURA et al.	: Examiner: H. Nguyen )	
Application No.: 09/811,419	: Group Art Unit: 2851	
Filed: March 20, 2001	: )	<del></del> ;
For: EXPOSURE APPARATUS, METHOD OF MANUFACTURING SEMICONDUCTOR DEVICES AND PLANT THEREFOR  Commissioner for Patents Washington, D.C. 20231	) April 26, 2002 :	RECEIVED APR 30 2002 ECHNOLOGY CENTER 2
Sir:		0082
Transmitted herewith is a Response to Restriction Re	equirement in the above-identified	d application.
X No additional fee is required.		

The fee has been calculated as shown below:

			CLAIMS AS AME	ENDED		
	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NO. PREVIOUSLY PAID FOR	PRESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL CLAIMS	15	MINUS	20	= 0	x \$9 \$18	\$0.00
INDEP. CLAIMS	2	MINUS	3	= 0	x \$42 \$84	\$0.00
Fee for Multip	ple Dependent claims	\$140/\$280				
TOTAL ADDITIONAL FEE FOR THIS AMENDMENT				\$0.00		

ĺ	°Verified Statement claiming small entity status is enclosed	if not filed previously	y
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	A check in the amount of \$ is encl	osed including the additional claims fee.
	Charge \$ to Deposit Account No. 06-1205. A c	duplicate of this sheet is enclosed.
X	Any prior general authorization to charge an issue for 06-1205 is hereby revoked. The Commissioner is hunder 37 CFR 1.16 and 1.17 which may be required or to credit any overpayment, to Deposit Account N enclosed.	nereby authorized to charge any additional fees during the entire pendency of this application,
X	A check in the amount of \$ to cover the fe	ee for a month extension is enclosed.
	A check in the amount of \$ to cover the Information	ation Disclosure Statement fee is enclosed.
X	Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should be directed to our address given below.	
	Respec	ctfully submitted,
	Steven	ey for Applicants a E. Warner ration No. 33,326

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#7/llic. 5-7-02

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SEMICONDUCTOR DEVICES AND PLANT THEREFOR	) April 26, 2002 :	APR 30 2
Commissioner for Patents Washington, D.C. 20231		IVED 0 2002 CENTER 2800

## RESPONSE TO RESTRICTION REQUIREMENT

Sir:

Applicants respectfully traverse the restriction requirement set forth in the Office Action dated April 3, 2002.

In the Office Action, the Examiner sets forth a restriction requirement between two groups of claims. Group I, claims 1-10 (and presumably claim 11), is drawn to an exposure apparatus, classified in class 355, subclass 30. Group II, claims 12-15, is drawn to a method of manufacturing a semiconductor device and a plant for manufacturing a semiconductor device, classified in class 430, subclass 311.

The Examiner contends that the inventions of Groups I and II are related as subcombinations disclosed as usable together in a single combination, and have acquired a separate status in the art due to their asserted "divergent subject matter" such that the searches are not coextensive, requiring separate examination. These contentions are respectfully traversed.

Applicants note that the inventions of Groups I and II are so closely related in the field of semiconductor exposure that a proper search of any of the claims would, of necessity, require a search of the others. Thus, it is submitted that all of the claims can be searched simultaneously, and that a duplicative search, with possibly inconsistent results, may occur if the restriction requirement is maintained.

Applicants further submit that any nominal burden placed upon the Examiner to search an additional subclass or two, necessary to determine the art relevant to Applicants' overall invention, is significantly outweighed by the public interest in not having to obtain and study several separate patents in order to have available all of the issued patent claims covering Applicants' invention. The alternative is to proceed with the filing of multiple applications, each consisting of generally the same disclosure, and each being subjected to essentially the same search, perhaps by different Examiners on different occasions. This places an unnecessary burden on both the Patent and Trademark Office and on Applicants.

In the interest of economy, for the Office, for the public-at-large and for Applicants, reconsideration and withdrawal of the restriction requirement are requested.

Nevertheless, in order to comply with the requirements of 37 CFR 1.143,

Applicants provisionally elect, with traverse, to prosecute the invention of Group I, namely claims 1-10 and, presumably, claim 11.

Favorable consideration and an early passage to issue are requested.

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should be directed to our address listed below.

Respectfully submitted,

Attorney for Applicants

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